# Electron-electron interaction correction and magnetoresistance in tilted fields in Si-based two-dimensional systems

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We study the diffusive electron-electron interaction correction to conductivity by analyzing simultaneously  $\rho_{xx}$  and  $\rho_{xy}$  for disordered 2D electron systems in Si in a tilted magnetic field. Tilting the field is shown to be a straightforward tool to disentangle spin and orbital effects. In particular, by changing the tilt angle we prove experimentally that in the field range  $g\mu_B B > k_B T$  the correction depends on the modulus of the magnetic field rather than on its direction, which is expected for a system with isotropic *g* factor. In the high-field limit, the correction behaves as  $\ln(B)$ , as expected theoretically [Lee and Ramakrishnan, Phys. Rev. B **26**, 4009 (1982)]. Our data prove that the diffusive electron-electron interaction correction to conductivity is not solely responsible for the huge and temperature-dependent magnetoresistance in a parallel field, typically observed in Si-MOSFETs.

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### I. INTRODUCTION

A diffusive electron-electron interaction correction (EEC) to the conductivity was predicted theoretically<sup>1</sup> about 30 years ago. In 2D systems, it is proportional to  $\ln(\hbar/k_BT\tau)$  ( $\tau$  is the momentum relaxation time) and grows in amplitude as temperature decreases. A way to experimentally single-out EEC among other numerous effects is based on its property not to affect the Hall component of magnetoconductivity tensor  $\sigma_{xy}$  in a perpendicular magnetic field.<sup>2</sup> EEC therefore gives birth to a temperature-dependent and parabolic with field contribution to the diagonal magnetoresistance  $\rho_{xx}(B)$  and a correction to the Hall coefficient  $\rho_{xy}/B$ , both being proportional to  $\ln(\hbar/k_B T \tau)$ . The predicted features were observed in numerous experiments, mainly with *n*-type GaAs-based 2D systems.<sup>3–6</sup> However, the quantitative level of agreement between theory and experiment was achieved only in the 2000's by the Minkov group<sup>7</sup> from simultaneous analysis of both Hall and diagonal components of resistivity tensor. The suggested method was later approbated by others.<sup>8–10</sup> We note that the Zeeman splitting effects were negligible in most of the studied systems.

The Zeeman splitting was predicted to decrease the EEC value,<sup>11</sup> the physical interpretation of this effect introduced later in Ref. 12 consists in decreasing the effective number of triplet channels with field. For the diffusive regime  $k_B T \tau / \hbar \ll$  1, the EEC is predicted to be quadratic in field in the low-field limit, and proportional to the logarithm of the field in the high-field limit.

Experimentally, however, the effect of the Zeeman splitting on EEC in the diffusive regime was only briefly considered in Refs. 13–15. For the most ubiquitous 2D system known, 2DEG in Si-MOSFET, which fits well all theory requirements, no convincing measurements of the EEC have been done so far. At the same time, this system demonstrates positive magnetoresistance in parallel field, the behavior expected for EEC. In the 1980's, there were attempts to reveal EEC in Si from the temperature and magnetic field dependencies<sup>16–18</sup> of resistivity; these attempts were based on not yet developed theoretical concepts and did not lead to a self-consistent picture of magnetotransport.

Interest to the Zeeman splitting effects was resumed in 1997 with the observation of a huge rise in resistivity of 2DEG in clean Si-MOSFETs in parallel magnetic field,<sup>19-21</sup> close to metal-to-insulator transition. The interest further increased with an interpretation of this magnetoresistance as a signature of a magnetic quantum phase transition.<sup>22,23</sup> In the 2000's, several attempts to treat the parallel field magnetoresistance (MR) in terms of renormalization-group approach were taken both theoretically<sup>24</sup> and experimentally.<sup>25,26</sup> This approach is, in fact, a self-consistent generalization of the EEC for arbitrary interaction strength and conduction. Independently, another theoretical approach was developed in Refs. 27–29, and successfully applied,<sup>30</sup> which accounts for a resistivity increase with field simply by renormalization of the density of states and single impurity scattering time. The latter effect is essentially different from the logarithmic EEC, which emerges from multiple electron-impurity scattering.

The experimental situation, however, is more complicated: studies<sup>31,32</sup> showed a strong effect of disorder on the parallel field magnetoresistance, that was discussed in terms of the band tail effects in Refs. 33 and 34. Moreover, detailed studies of the MR on different material systems<sup>14,18,35–37</sup> did demonstrate quantitative disagreement between the fitted-to-EEC theory temperature and magnetic field dependencies of the conductivity.

To summarize the present state of the field, there seems to be a common agreement on the Zeeman nature of parallel field MR in 2D carrier systems. However, two conceptually different underlining mechanisms of MR were put forward: (i) EEC (multiple-scattering effect) and (ii) screening change in magnetic field (single-scattering effect). Which of them is responsible for the experimentally observed strong MR in parallel field? The answer is especially crucial in the vicinity of the metal-to-insulator transition, where the MR is dramatically strong. Unfortunately, both theories become inapplicable in this regime of small conductances  $\sigma \sim e^2/2\pi\hbar$ . To address this issue, we have chosen to approach the problem from the large conductance regime, where both theories have solid ground, though the MR is low. In our paper, we contest possible origins of the parallel field magnetoresistance of weakly interacting 2D electron gas. In order to study EEC, we take detailed measurements of the magnetoresistance tensor in tilted field, and analyze the data using the procedure developed in Refs. 7 and 13. We stress that our approach does not rely on any particular microscopic theory, rather, it is *ab initio* phenomenological and uses only the general property of the EEC in the diffusive regime to affect  $\sigma_{xx}$  solely.

For the experiments, we have chosen the simplest model system, the 2D electron gas in Si in the diffusive regime,  $k_B T \tau / \hbar \ll 1$ ,  $\sigma \gg e^2/2\pi\hbar$ . To vary the strength of the Zeeman splitting, and thus, the EEC magnitude, we tilted the magnetic field with respect to the 2D plane. This procedure allowed us to extract EEC on top of other magnetoresistivity effects and to establish two principally different regions: (i) a high-field region, where EEC depends on the total field and quantitatively agrees with the theoretically predicted ln(*B*) asymptotics and (ii) a low-field region, where EEC unexpectedly depends on the perpendicular field component, grows with field, and does not match existing theories.

Our observations suggest a new insight on the origin of the parallel field MR: (i) the high-field small and *T*-independent EEC  $\Delta\sigma(B) \propto \ln(B)$ , revealed in the current study, can not be responsible for large and *T*-dependent parallel field MR, and (ii) application of even low  $g\mu_B B \sim k_B T$  perpendicular field component strongly suppresses MR. The latter fact proves not purely spin nature of the parallel field MR and points at the incompleteness of the existing theory of MR.

The paper is organized as follows. After a brief description of experimental details in Sec. II, we give theoretical background in Sec. III, and describe the results in Sec. IV, first on the EEC, then on the experimental proof of the Zeeman origin of the magnetic field effect on EEC, and further we compare the known EEC with the parallel field magnetoresistance to show that the EEC is not the main origin of the parallel field magnetoresistance. In Sec. V, we discuss the obtained results.

#### **II. EXPERIMENTAL DETAILS**

The ac-measurements (13 to 73 Hz) of the resistivity were performed at temperatures 0.3-25 K in magnetic fields up to 15 T with two (100) Si-MOS samples with 200-nm oxide thickness: Si-40, (peak mobility  $\mu_{peak} = 0.2 \text{ m}^2/\text{Vs}$ at T = 0.4 K) and Si-24 (0.22 m<sup>2</sup>/Vs). The samples were lithographically defined as rectangular Hall bars of the size  $0.8 \times 5$  mm<sup>2</sup>. To obtain the data for different orientations of magnetic field relative to the 2D plane, the sample platform was rotated in situ at low temperature using a step motor. Because of the smallness of the studied effects and unavoidable misalignment of potential contacts, there always was some asymmetry (within less than a few percents) of both  $V_x$  and  $V_y$  with respect to a field reversal at a constant  $j_x$  (~50 nA) current direction. To compensate this asymmetry, the field was swept from positive to negative values and the data were symmetrized. The alignment of the sample parallel to magnetic field was done using the resistivity peak due to weak localization. The carrier density n was varied by the gate voltage in the range  $(8-35) \times 10^{11}$  cm<sup>-2</sup>. The field was tilted in the zy plane, always perpendicular to the current direction, which is, however, not crucial for Si because of weak spin-orbit coupling.<sup>32</sup>

We have selected samples with moderate carrier mobility in order to ensure studies deep in the diffusive regime 0.005 <  $k_B T \tau/\hbar < 0.2$ , where EEC theory should be applicable, and at the same time to achieve  $\mu B \sim 1$  in available magnetic field. Other features that make the Si-MOS system preferable for this study are (i) short-range and uncorrelated scatterers, which make motion diffusive, (ii) large conductance  $k_F l \sim 2-15$ , which ensures that the quantum correction theory is applicable, (iii) very thin potential well <5 nm, which excludes orbital effects in parallel magnetic fields up to 20 T, and (iv) filling of the lowest size quantization subband solely for  $n < 3.5 \times 10^{12}$ cm<sup>-2</sup> with effective mass  $m^* \approx 0.2m_e$ .<sup>35,38</sup>

## **III. THEORETICAL BACKGROUND**

The idea of the present study is based on a property of the e-e correction to affect only the diagonal component of the conductivity tensor:<sup>2,39</sup>

$$\sigma = \frac{ne\mu}{1+\mu^2 B_{\perp}^2} \begin{pmatrix} 1 & \mu B_{\perp} \\ -\mu B_{\perp} & 1 \end{pmatrix} + \begin{pmatrix} \Delta \sigma & 0 \\ 0 & \Delta \sigma \end{pmatrix}.$$
(1)

Correspondingly, the procedure of the EEC extraction<sup>7</sup> for arbitrary  $(\Delta\sigma/ne\mu)$  value includes the following steps: (i) by reversing the measured resistivity tensor one calculates the conductivity tensor. (ii) From  $\sigma_{xy}$  one finds the mobility  $\mu$  value, using the experimentally determined density n.<sup>40</sup> (iii) By subtracting  $ne\mu/(1 + \mu^2 B_{\perp}^2)$  from  $\sigma_{xx}$ , one finds the correction  $\Delta\sigma(B,T)$ . The mobility  $\mu(B,T,n)$  value is a byproduct of this algorithm.

If the conductivity is large,  $ne\mu \gg \Delta\sigma \sim e^2/2\pi^2\hbar$ , the above algorithm leads to the following expressions for the resistivity components:

$$\rho_{xx} = 1/ne\mu \times [1 - (1 - \mu^2 B^2)\Delta\sigma/ne\mu], \qquad (2)$$

$$\rho_{xy} = B_{\perp}/ne \times (1 - 2\Delta\sigma/ne\mu). \tag{3}$$

As we checked, these formulas are valid for all our data with  $\rho_{xx} < 4$  kOhm.

In practice, both  $\Delta\sigma$  and mobility  $\mu$  in Eqs. (1)–(3) might depend on *B* and *T* thus incorporating other possible magnetoresistance effects. Nevertheless, as follows from Eq. (3), no matter how the mobility depends on field, the correction to the Hall coefficient arises from EEC solely.

Depending on the geometry of experiment the following cases are possible: (i) the field is directed normally to the sample plane,  $B = B_{\perp}$ , during the sweep (this case refers to most of the previous studies). (ii) The field is inclined by an angle  $\theta$  relative to the 2D plane, in order to enhance the Zeeman effects, which depend on  $B = B_{\perp}/\cos(\theta)$ . (iii) The field magnitude |B| remains constant while the sample is rotated relative to the field direction; in the latter case, one expects the Zeeman effects to remain unchanged, thus leading to the angle-independent  $\Delta \sigma$ . We note here that in the case of geometry (ii) data processing requires knowledge of the ratio  $B_{\perp}/ne$  solely, rather than the tilt angle. According to

our definition of density,<sup>40</sup> the  $B_{\perp}/ne$  ratio is obtained from the measured linear-in-total-field high-temperature limit of the Hall resistance  $R_{xy}^{HT}(B) = B_{\perp}/ne$ . We find this limit by linear extrapolation of  $R_{xy}(B)$  to the highest temperatures (typically 15 K) and by ignoring low-field effects (see below).

Making use of geometries (ii) and (iii) is the key feature of the present study. We note here that the *g* factor in Si is large (g = 2) and isotropic, which insures the Zeeman effects to be tilt independent. In systems with an anisotropic *g* factor, like holes in GaAs,<sup>13</sup> one should take into account different components of the *g*-factor tensor, which complicates the problem.

According to the theory of interaction corrections<sup>1,41</sup> in its modern form,  $^{24,42,43}$  the EEC value at zero magnetic field in the diffusive regime is<sup>44</sup>

$$\Delta\sigma = \frac{e^2 \ln(k_B T \tau/\hbar)}{\pi^2 \hbar} \bigg\{ 1 + n_T \bigg[ 1 - \frac{\ln\left(F_0^{\sigma} + 1\right)}{F_0^{\sigma}} \bigg] \bigg\}, \qquad (4)$$

where  $F_0^{\sigma}$  is a Fermi-liquid constant,  $n_T = 4n_v^2 - 1$  is the number of triplet channels of interaction,  $n_v$  is the valley degeneracy (in the original formula<sup>1,41</sup>  $n_T = 3$ ). In (001) Si-MOSFETs, the electron system is twofold valley degenerate, and the degeneracy, if perfect, should increase  $n_T$  to 15.<sup>45</sup> In fact, however, this degeneracy is never perfect, because of the two sample-dependent parameters, a finite valley splitting  $\Delta_v$ ,<sup>38</sup> and intervalley scattering time  $\tau_v \sim 10\tau \approx 1/4$  K<sup>-1</sup> for the sample Si-40.<sup>46</sup> Both effects decrease the number of triplet terms, which was described theoretically<sup>24</sup> and studied experimentally.<sup>35,47</sup>

The problem with MOSFETs is that  $\Delta_v$  (which is typically less than  $1/\tau$ ) can hardly be measured directly in zero- and low-magnetic fields, because valley splitting of Shubnikov-de Haas oscillations does not exceed level broadening and hence can not be resolved.<sup>48</sup> One could treat  $\Delta_v$  as an additional free parameter, which vary in the range from 0 to  $1/\tau$ , strongly affecting predictions of the *e-e* interaction correction theory.<sup>24,42</sup> Within the present study, the uncertainty of the  $\Delta_v$ value affects only the effective number of valleys  $n_v$  that can vary from  $n_v = 2$  to  $n_v = 1$ . We therefore can use  $n_v$  as an adjustable parameter, which quantifies the effective degree of valley multiplicity.

In 2001, the EEC was recalculated by Zala *et al.*<sup>43</sup> and a new "ballistic" contribution was introduced that gave explanation to  $\rho(T) \propto T$  dependence observed in different 2D systems in the regime  $k_B T \tau/\hbar > 1.^{36,49}$  It was shown experimentally<sup>8,9,50</sup> that the ballistic and diffusive corrections differ fundamentally: diffusive EEC does not affect the Hall component of conductivity tensor [see Eq. (1)], whereas the ballistic contribution is basically the renormalization of the single-impurity scattering time or mobility. In the present study, we do not consider the ballistic contribution, rather, we extract from the experimental data and analyze the diffusive part of the EEC solely.

A theoretical prediction for the Zeeman splitting dependence of the EEC was given in Ref. 11:

$$\Delta\sigma = -\frac{e^2}{2\pi^2\hbar}\lambda_D g_2(h),\tag{5}$$

where  $h = g\mu_B B/k_B T$ , and the two asymptotics for  $g_2(h)$  function are

$$g_2(h) = 0.084h^2, \quad h \ll 1,$$
 (6)

$$g_2(h) = \ln(h/1.3), \quad h \gg 1.$$
 (7)

Within the same theoretical formalism, the Zeeman splitting effect on ballistic and diffusive corrections to magnetoresistance in parallel field was recalculated in Ref. 12. Although the theory was successfully used to fit some data on parallel field magnetoresistance,<sup>37</sup> the procedure of the comparison with theory is ill defined and requires careful separation of the diffusive and ballistic EEC contributions in the crossover regime. Since our method catches only the diffusive part, we briefly discuss below modern theoretical expressions in the diffusive regime  $k_B T \tau/\hbar \ll 1$  solely:

$$\Delta\sigma(h) = \frac{e^2}{2\pi^2\hbar} n_v^2 \frac{0.091F_0^{\sigma}}{\left(1 + F_0^{\sigma}\right)^2} h^2, \quad h \ll 1.$$
(8)

This low-field limit is close to Ref. 11 for small  $|F_0^{\sigma}| \ll 1$ . In the high-field limit, the diffusive contribution from Ref. 12 is given by

$$\Delta \sigma = \frac{e^2}{2\pi^2 \hbar} 2n_v^2 \left[ 1 - \frac{\ln\left(F_0^{\sigma} + 1\right)}{F_0^{\sigma}} \right] \ln \frac{h}{F_0^{\sigma} + 1}, \quad h \gg 1.$$
(9)

Noteworthy, functional dependence on  $F_0^{\sigma}$  is the same for Eqs. (4) and (9). This fact has a transparent physical meaning: application of high field  $h \gg 1$  suppresses temperature dependence of only  $2n_v^2$  triplets with  $s_z = 0$ . This suppression comes from an expansion of the  $\ln(h) = \ln(g\mu_B B) - \ln(k_B T)$ . Correspondingly, if we define

$$\lambda = 1 - \ln \left( F_0^{\sigma} + 1 \right) / F_0^{\sigma}, \tag{10}$$

we may rewrite the theoretical expectation for the lowtemperature  $(T \ll 1/\tau \ll E_F)$  high-field  $(k_B T \ll g\mu_B B \ll E_F)$  asymptotics:

$$\Delta\sigma(T,B) = C + \frac{e^2}{2\pi^2\hbar} \Big[ \Big( 1 + 2n_v^2\lambda - \lambda \Big) \ln(T) + 2n_v^2\lambda \ln(B) \Big].$$
(11)

Here, *C* is a *T*- and *B*-independent term. This expression allows one to compare experimental data on low-temperature high-field asymptotics of the EEC with the microscopic theory predictions. Its meaning is as follows: in the high-field limit  $h \gg 1$ , the magnetic field dependence is not affected by temperature. In Appendix A, we show that from the practical point of view, this limit is achieved already for h > 2.

To conclude this section, studying magnetoresistance in a purely parallel field is insufficient to disentangle the ballistic and EEC contributions. Tilting the field enables one to overcome this drawback. As shown in the next section, application of high tilted fields allows us to achieve in experiment the asymptotical  $\Delta\sigma(T,B)$  behavior for which there is a firm theory prediction.

## **IV. RESULTS**

This section is organized as follows: in the first section, we discuss phenomenology, the low-field regime and an experimental proof of the EEC dependence on the modulus of the magnetic field rather than on its direction. In the second section, we consider high-field asymptotics of the EEC, and compare them with the Fermi-liquid theory expectations. In the third section, we discuss magnetoresistance in parallel and tilted fields.

#### A. Tilt angle independence of the EEC

We explore MR in the range of fields  $B_{\rm tr} < B_{\perp} < 1/\mu$ , i.e., in the domain between weak localization,  $B_{\rm tr} = (hc/e)(1/4\pi l^2)$  and Shubnikov-de Haas oscillations (here, l is the transport mean free path). Figure 1(a) shows magnetoresistance  $\rho_{xx}$  and Hall resistance  $\rho_{xy}$  versus  $B_{\perp}$  in a field up to  $1/\mu \approx 6$  T. The data were collected at various temperatures (0.6–4.2 K) in a standard geometry (magnetic field perpendicular to the sample plane) for sample Si-40 at  $n = 1.25 \times 10^{12}$  cm<sup>-2</sup>. The set of curves for Si [see Fig. 1(a)] does not look similar to numerous data for *n*-GaAs 2D systems.<sup>3–9</sup> Indeed, there are two important features: (i) unlike GaAs, for Si in high fields [>1 T in Fig. 1(a)], the MR gets weaker and ultimately even changes sign to positive as temperature decreases and (ii) the Shubnikov-de Haas oscillations start to appear already in fields  $B_{\perp} < \mu^{-1} \approx 6$  T due to short-range disorder.

Because of the above features, the EEC is not seen straightforwardly from the data. Therefore, in order to extract it, we use the procedure described in the previous section. At the first step, we invert the resistivity tensor and obtain the conductivity one [solid lines in Figs. 1(c) and 1(e)]. The Hall component of the conductivity tensor allows one to calculate the mobility  $\mu$  using Eq. (1) [shown in Fig. 1(d)]. Surprisingly, the mobility appears to be field dependent (unlike that in experiments with GaAs<sup>7</sup>); in strong fields (B > 1 T), the higher is the temperature the stronger is the field dependence. This effect is beyond the scope of the present study, we note only that the sign of the  $\mu(B)$  dependence is in line with expectations from memory effects<sup>51</sup> though such effects do not produce a temperature dependence. The field-dependent mobility was suggested to arise also from the ballistic correction  $\delta \sigma_{xy}(B,T) \propto \sqrt{T}/B$ .<sup>52</sup> Even though such a correction looks qualitatively similar to our data, it is hardly relevant, because originates from multiple cyclotron returns and should be valid for  $k_B T \tau / \hbar \gg 1$ ,  $\hbar \omega_c \gg k_B T$ , which is not the case.

In weak fields, the Hall mobility increases as *B* decreases due to an increase of the Hall slope. Having the mobility known, we calculate the Drude part of  $\sigma_{xx}$ ,  $ne\mu/(1 + \mu^2 B^2)$ [shown by dotted lines in Fig. 1(e)]. The correction to conductivity  $\Delta\sigma$  is calculated as a difference between  $\sigma_{xx}$  and its Drude expectation [see inset to Fig. 1(e) for the graphical definition]. The resultant  $\Delta\sigma(B)$  is shown by solid lines in Fig. 1(f). As it is clear from Eq. (3), the correction resembles the behavior of the Hall coefficient  $\rho_{xy}/B$  [shown in Fig. 1(f)]: the larger the Hall coefficient, the less the correction.

All  $\Delta\sigma(B_{\perp})$  dependencies (collected at different temperatures, densities, tilt angles, and for different samples) manifest similar behavior; in low fields [region A in Fig. 1(g)],  $\Delta\sigma$ 



FIG. 1. (Color online) Magnetoresistivity tensor components for various temperatures (0.6, 1.3, 2.5, and 4.2 K): (a)  $\rho_{xx}$ , and (b)  $\rho_{xy}$ vs perpendicular magnetic field. (c) Hall conductivity  $\sigma_{xy}$  calculated from the data. (d) Mobility  $\mu$ , calculated from the Hall conductivity using Eq. (1). (e) Solid lines:  $\sigma_{xx}$  calculated by inverting the measured resistivity tensor [(a) and (b)]. Dotted lines: Drude value of  $\sigma_{xx}$ calculated using mobility from (d). The inset blows up the data to show graphically the definition of  $\Delta \sigma$ . (f) Hall angle  $\rho_{xy}/B$  for the same data set. (g) Solid lines: EEC vs magnetic field recalculated from the data. Dashed lines: EEC at the very same set of temperatures vs total magnetic field for the sample tilted by 45°. Bold line separates the low-field and high-field regimes, denoted A and B, respectively. Sample Si-40, electron density  $n = 1.25 \times 10^{12}$  cm<sup>-2</sup>.

grows as *B* increases, then reaches a maximum and decreases in the high-field region B. In the low-field region A, the feature in  $\Delta\sigma$  originates from the nonlinearity of the Hall resistance with field [as seen from Fig. 1(f)]. A similar low-field feature was observed in numerous previous studies with various 2D systems;<sup>10,53–55</sup> it is still poorly understood. In Appendix B, we summarize our observations on the low-field Hall nonlinearity and argue that this low-field feature does not follow contemporary theories. Empirically, the boundary between the regions A and B (a point where  $\Delta\sigma$  is maximal) roughly follows the equation  $B_{\text{crossover}} \approx \sqrt{B_{\text{tr}}^2 + (k_B T/g\mu_B)^2}$ .

The correction decreasing with increasing field in the region B [see Fig. 1(g)] is qualitatively in line with the Zeeman splitting effect.<sup>11–13</sup> The latter should be direction independent, as discussed above. To check this property, we set the tilt angle to  $45^{\circ}$  and measured both  $\rho_{xx}$  and  $\rho_{xy}$  for the same temperatures and recalculated the EEC. The resultant EEC versus *total* magnetic field is shown in Fig. 1(g) by dashed lines. In the high-field region B, the monotonic parts of the EEC data (ignoring Shubnikov-de Haas oscillations) in perpendicular and tilted field are quantitatively similar to each other, even though the perpendicular component of the field differs by a factor of  $\sqrt{2}$ . This observation proves the Zeeman nature of the EEC in the high-field region.

Another instructive way to check whether  $\Delta\sigma$  depends on the *total* field is to rotate the sample in constant field. During these measurements, the tilt angle  $\theta$  was slowly swept at a constant rate using a step motor. We used positions of the specific sharp mirror symmetric features in the  $\rho_{xx}(\theta)$ dependence at  $\theta = 0$ ,  $\pi/2$ ,  $\pi$  to calibrate the angle and calculate the perpendicular component of the field. Figure 2 shows  $\rho_{xx}(B_{\perp})$  and  $\rho_{xy}(B_{\perp})$  for the same electron density and different temperatures. The inset in Fig. 2 shows the corresponding EEC. It is easy to see that gradual changes of  $\Delta\sigma$  with  $B_{\perp}$ , which were seen in Fig. 1(g) almost disappeared in the inset to Fig. 2; this demonstrates that EEC remains unchanged in constant total field.

We stress the importance of this "rotating field" experiment; indeed, the coincidence of  $\Delta\sigma(B)$  curves in Fig. 1(g) for different tilt angles is not a complete proof for directionindependence of the EEC, because it does not exclude corrections to conductivity  $\propto \ln(B_{\perp})$  (see, e.g., Ref. 56). In the latter case, one would see just a constant shift  $\propto \ln[\cos(\theta)]$ in a tilted field sweep experiment [see Fig. 1(f)] with no visible



FIG. 2. (Color online) Resistivity tensor components for sample Si-40 at different temperatures (0.6, 1.7, 4, and 8 K) versus perpendicular to the sample plane field component  $B_{\perp} = B_0 \cos(\theta)$ .  $n = 1.25 \times 10^{12} \text{ cm}^{-2}$ . The data were obtained by sweeping angle  $\theta$  (geometry of the experiment is shown in the left part of the figure) at constant magnetic field  $B_0 = 6$  T. Inset shows EEC vs  $B_{\perp}$  recalculated from the data in the main panel (solid curves). Dotted lines are the corresponding field-independent values of the EEC.

change in the functional form of the  $\Delta\sigma(B)$  dependence. In contrast, in the rotating field experiment, such corrections would reveal themselves as inclined  $\Delta\sigma(B_{\perp})$  lines, which is not the case in the insert to Fig. 2.

#### B. High-field asymptotics of the EEC

The discussed above field direction independence of the EEC was tested with two samples in the density range  $n = (1-3) \times 10^{12} \text{ cm}^{-2}$ , which corresponds to  $\sigma = (4-30) e^2/(2\pi\hbar)$ , and in the field range  $B_{\perp} < 1/\mu$ . The data in the high-field region B (B > T) should follow the asymptotics of Eq. (11). The field range for observing the logarithmic-in-field behavior, however, is limited on the low-field side by the low-field Hall feature (at  $B_{\perp} \sim 1$  T) and, on the high-field side, by the onset of Shubnikov-de Haas oscillations (at  $B_{\perp} \sim 1/\mu \sim 6$  T). For this reason, the field range for fitting the data with a ln(B) dependence is less than one decade.

We performed detailed measurements of magnetoresistivity tensor at different tilt angles in magnetic fields up to 15 T. The high-field asymptotes were fitted with a function

$$\Delta \sigma(B) = e^2 / (2\pi^2 \hbar) \left[ -D \ln(B) + A \ln(T) + C \right], \quad (12)$$

where A and D are two positive adjustable parameters, common for all curves. According to Eq. (11),  $A = (1 + 2n_v^2 \lambda - \lambda)$  and  $D = -2n_v^2 \lambda$ .

An example of the data and the corresponding EEC are shown in Fig. 3. One can see that the  $\Delta \sigma(B)$  dependencies for different temperatures follow almost parallel to each other, being only shifted vertically; exactly such behavior should be expected for the EEC correction according to Eq. (12). The temperature prefactor A can be easily found from the corresponding  $\Delta \sigma(T)$  dependence [see the inset in Fig. 3(b)]; for the given data set,  $A = 0.6 \pm 0.04$ . The data in the inset also demonstrate that the obtained A value is field independent for B > 5 T, which confirms that the analyzed data follow the high-field asymptotic behavior. As for the field-dependence prefactor D, since the accessible field interval is less than a decade and we do not know how far the low-field correction (caused by the Hall anomaly) may extend, we can only roughly estimate -0.3 < D < -0.15. Its lower bound is found from the low-field, B < 6 T, data and the upper bound from the high field (B > 10 T) data.

The next logical step would be to analyze the density dependencies of the two prefactors, *A* and *D*, and to check their consistency with each other and with a microscopic theory. Figure 4 shows magnetoresistance and the corresponding EEC for elevated density  $n = 2 \times 10^{12}$  cm<sup>-2</sup> and for the same tilt angle. Since the conductivity increases here by a factor of 2.5, the effect of EEC becomes less pronounced on top of the Drude conductivity, nevertheless, both the temperature and the magnetic field dependencies of the EEC remain approximately the same: A = 0.65; D = 0.2-0.4.

The resulting A and D values are summarized in Table I. As we argued above, these parameters do not demonstrate a pronounced density dependence. This fact is reasonable because in the studied range of densities (i) the interaction parameter  $r_s = (\pi n)^{-1/2}/a_B^{*38}$  is rather small ~1.5–2.8, and (ii) the conductivity is large compared to the quantum unit to



FIG. 3. (Color online) (a) and (b) Resistivity tensor components for sample Si-40 at various temperatures (0.3, 0.7, 1.6, 3, 7, and 15 K) vs total magnetic field (bottom axis) and perpendicular component (top axis).  $n = 1.25 \times 10^{12}$  cm<sup>-2</sup>;  $\theta = 62^{\circ}$ . (c) EEC calculated from the data in (a) and (b) (solid curves). Dash-dotted lines are a set of functions  $\Delta \sigma = -0.15 \ln(B) + C$ ; dotted lines show  $\Delta \sigma =$  $-0.3 \ln(B) + C$  (*C* values are adjusted to fit the high-field asymptotes of the EEC). An inset in (b) shows the obtained *T* dependence of the EEC. An inset in (b) shows the obtained *T* dependence of the EEC at B = 3 (crossed rectangles), 7.5 (empty rectangles), and 15 T (filled rectangles). Solid line is a linear-in-ln(*T*) fit of  $\Delta \sigma(T, 15 \text{ T}) = \frac{e^2}{2\pi^2 h} 0.65 \ln(T/7.5 \text{ K})$ , dotted line is a linear-in-ln(*T*) fit of  $\Delta \sigma(T, 3 \text{ T}) = \frac{e^2}{2\pi^2 h} 0.58 \ln(T/5.6 \text{ K})$ .

ensure smallness of the renormalization effects.<sup>45,57</sup> In Table I, we present  $F_0^{\sigma}$  calculated from A and D values using Eqs. (10) and (11) for the effective valley multiplicity  $n_v = 1$  and 2. For comparison, we also show the  $F_0^{\sigma}$  values experimentally determined from Shubnikov-de Haas oscillations<sup>58</sup> and from R(T) ballistic dependencies.<sup>35</sup> Firstly,  $|F_0^{\sigma}|$  extracted from A decreases with density. Secondly,  $|F_0^{\sigma}|$  values extracted from A for  $n_v = 2$  are rather close to the earlier measured values. If we adopt the effective valley multiplicity  $n_v$  to be somewhat smaller than 2, the agreement will become even better. When making such comparison with earlier data, one should keep in mind that previous results were obtained in the high-temperature ballistic regime, where both valleys contribute equally and  $n_v = 2$  exactly. One should also take into account that the  $|F_0^{\sigma}|$  values for the diffusive (this work) and ballistic (previous data<sup>35,58</sup>) regimes should not coincide, for the reasons discussed in Ref. 43. We therefore conclude the temperature dependence of the diffusive EEC (i.e., A values) to agree quantitatively with earlier data and to agree qualitatively with theory.



FIG. 4. (Color online) (a) and (b) Resistivity tensor components for sample Si-40 at various temperatures (0.3, 0.7, 1.6, 3.3, 7, and 15 K) vs the total magnetic field (bottom axis) and the perpendicular component (top axis).  $n = 2 \times 10^{12} \text{ cm}^{-2}$ ;  $\theta = 62^{\circ}$ . (c) EEC calculated from the data in (a) and (b) (solid curves). Dash-dotted lines are a set of functions  $\Delta \sigma = -0.22 \ln(B) + C$  with different *C*, which gives satisfactory high-field asymptotes of the EEC (see text). An inset shows the obtained  $\Delta \sigma(T)$  dependence collected at 2 (empty rectangles), 4 (crossed rectangles), and 8 T (black rectangles). Solid line is a fit of the high-field (8 T) data with a logarithmic function,  $\Delta \sigma = \frac{e^2}{2\pi^2 \hbar} \times 0.65 \ln(T/6.4 \text{ K})$ ; dashed line is a fit of the low-field (2 T) data with a logarithmic function,  $\Delta \sigma = \frac{e^2}{2\pi^2 \hbar} \times 0.5 \ln(T/8 \text{ K})$ .

Possible reasons for the large uncertainty in *D* values and their poor consistency with *A* values may be (i) the too narrow range of fields accessible for identifying  $\ln(B)$  dependence (see above) and (ii) the effective number of valleys ( $1 < n_v < 2$ ) may be different in the field and temperature dependencies.

TABLE I. Summary of interaction parameters found from the EEC measurements.

$n, 10^{12} \text{cm}^{-2}$	0.9	1.25	2	3
$\rho_D$ , kOhm	8	4	2	0.9
$r_s$	2.77	2.35	1.86	1.52
$F_0^{\sigma} \exp^{35,58}$	-0.25	-0.2	-0.13	-0.076
A	0.25	$0.6\pm0.04$	$0.65\pm0.05$	$0.65\pm0.06$
$F_0^{\sigma}(A)  n_v = 1$	-0.72	$-0.52\pm0.04$	$-0.47\pm0.05$	$-0.47\pm0.06$
$F_0^{\sigma}(A)  n_v = 2$	-0.2	$-0.12\pm0.01$	$-0.1\pm0.02$	$-0.1\pm0.02$
D		0.15-0.3	0.2-0.4	0.2-0.4
$F_0^{\sigma}(D)  n_v = 1$		$-0.20\pm0.07$	-0.17 - 0.32	-0.17 - 0.32
$F_0^{\sigma}(D)  n_v = 2$		$-0.06\pm0.02$	-0.05 - 0.09	-0.05 - 0.09

For the lowest studied density  $n = 0.9 \times 10^{12}$  cm<sup>-2</sup>, the low-field feature broadens and obscures an observation of the decreasing logarithmic  $\Delta\sigma(B)$  dependence; this prevented us from measuring the respective *D* values.

To summarize this section, we presented above three firm experimental observations on the high-field and lowtemperature behavior of the EEC, as follows: (i) the observed  $\Delta\sigma(B,T)$  dependencies do not demonstrate any anisotropy with respect to the field direction, (ii)  $\Delta\sigma$  is linear both in ln(*B*) and ln(*T*) in line with the expected asymptotics [see Eq. (11)], and (iii) the observed field and temperature dependencies have an anticipated magnitude. In total, the above listed facts prove that the field and temperature dependencies of conductivity indeed represent the EEC. The prefactor in the temperature dependence of  $\Delta\sigma$  reproduces  $|F_0^{\sigma}|$  values that are decreasing with density and are reasonably consistent with earlier data. The prefactor in the ln(*B*) dependence does not contradict the microscopic theory and earlier data though it was determined with rather large uncertainty.

### C. Magnetoresistance

A nonmonotonic magnetoresistance in perpendicular field and at low temperatures in Si and *p*-SiGe has been observed since 1982:<sup>14,16,59</sup> as field increases, the drop in  $\rho_{xx}$  due to weak localization is followed by the resistivity increase [see, e.g., Fig. 1(a)]. Surprisingly, the effect has not been discussed and understood yet. As can be seen from our data [see Fig. 3(a), field tilting makes this effect even more pronounced, thus pointing to the Zeeman nature of the nonmonotonic magnetoresistance. Qualitatively, this seems to be transparent: the larger is the Zeeman field, the stronger is the positive component of magnetoresistance. In the strictly parallel field orientation there is no weak localization suppression and the magnetoresistance is purely positive. Following Castellani et  $al.,^{60}$  the magnetoresistance in the diffusive regime for 2D systems was often attributed to EEC<sup>26</sup> and used to evaluate the interaction parameter.<sup>25,49</sup> However, whether the observed parallel field magnetoresistance may be entirely attributed to EEC, has not been proven so far.

Having developed a technique to measure the Zeeman field dependence of the EEC directly, with no adjustable parameters, we can compare now EEC with magnetoresistance. Figure 5(a) shows a set of magnetoresistance curves collected at different temperatures for  $n = 1.25 \times 10^{12}$  cm<sup>-2</sup> in the parallel field orientation. The high-field asymptotics of EEC for the same sample and same density  $\Delta \sigma = C + 0.15 \ln(B)$  is also shown in Fig. 5(a) by a dashed line (the prefactor 0.15 for this particular density is found in the previous section). The observed magnetoresistance appears to be (i) an order of magnitude larger than EEC and (ii) has much stronger temperature dependence; therefore it is mainly of a different origin. This is one of the key results of the present study, it brings into a question the validity of using the parallel field magnetoresistance for finding the interaction constant.

We have shown above that the multiple scattering (EEC) approach leads to much smaller magnetoresistance than that observed; we test below whether or not single impurity scattering processes play a dominant role in magnetoresistance. We show in Fig. 5(a) (dotted lines) the magnetocondutivity



FIG. 5. (Color online) (a) Parallel magnetic field magnetoresistance for Si-40,  $n = 1.25 \times 10^{12}$  cm<sup>-2</sup> (solid lines). The direction of the temperature (0.6, 1.3, 2.2, and 4 K) change is indicated by an arrow. Right axis is in conductivity units. Dotted curves are the theory prediction<sup>12,37</sup> for the two-valley system,  $F_0^{\sigma} = -0.2$ ,  $\Delta_v = 0$ . Dashed curve is the experimentally determined high-field limit of the EEC  $[C + 0.15 \ln(B)]$ . (b) Resistivity vs total magnetic field for Si-40,  $n = 1.25 \times 10^{12}$  cm<sup>-2</sup>, T = 0.6 K for different tilt angles (shown in the figure) with the lowest curve being field perpendicular to the sample plane 0°, and the highest positive slope curve 90° being parallel to the sample plane. "6-T rotation" curve shows magnetoresistance vs perpendicular component of the field for a fixed total field of 6 T.

calculated according to Eq. (4) from Ref. 37 (two-valley version of theory<sup>12</sup>) for a system with  $\Delta_v = 0$ ,  $\tau_v^{-1} = 0$ , and  $F_0^{\sigma} = -0.2$ . The calculated theory curve seems to demonstrate a reasonable agreement with the same experimental data. This agreement [in contrast to above sharp disagreement, see the dashed curve in Fig. 5(a)] has a simple physical explanation: the calculated curve comprises mainly (more than 65%) single impurity scattering renormalization, and only 35% of the diffusive EEC. We believe that by using two different  $F_0^{\sigma}$  values for ballistic and diffusive contributions<sup>43</sup> and by introducing finite valley splitting and intervalley scattering rate<sup>42</sup> (i.e., about four adjustable parameters), one can achieve a perfect agreement with experiment. This exercise reproduces an apparent successful comparison of the parallel field magnetoresistance data in Si-MOSFETs<sup>35,37</sup> with theory.<sup>12</sup>

Is this the end of the story and have we achieved a complete understanding of the magnetoresistance in the 2D system? Our answer is *no*; in order to argue this point, we apply a perpendicular field. Theoretically,<sup>52</sup> the Zeeman field-induced magnetoresistance should remain the same in a tilted field. Figure 5(b) shows the magnetoresistance at fixed T = 0.6 K and  $n = 1.25 \times 10^{12}$  cm<sup>-2</sup> for various tilt angles. In a perpendicular field (0° curve), as field increases from zero, weak localization becomes suppressed, leading to the negative magnetoresistance; further, we observe almost flat magnetoresistance until the onset of Shubnikov-de Haas oscillations. Such classically flat magnetoresistance is a signature

of a field-independent mobility. In the opposite limit of parallel field (90° curve), we observe a huge, 25% magnetoresistance in a field of 6 T. This fact itself is remarkable because we did not expect much difference between the parallel and perpendicular configurations in fields  $B > B_{tr}$  within the above simple considerations.

Although we do not believe in the orbital origin of the parallel field magnetoresistance, let us assume for a moment that only the parallel component of the field affects the mobility. If this is so, then by tilting the field from a purely in-plane direction (90°) to slightly out of plane (75°), when the parallel component of the field decreases only by 4%, we would expect roughly the same positive magnetoresistance as that in the purely parallel field. Surprisingly, after a suppression of the weak localization, we observed that the positive upturn in magnetoresistance is quite shallow and is no more than  $\sim 6\%$ ! For intermediate tilt angle (45°), the magnetoresistance [see Fig. 5(b)] only slightly deviates from the perpendicular field data, which further confirms a suppression of the parallel field MR by the perpendicular component.

To summarize our observations, the positive magnetoresistance that is weak in perpendicular and tilted fields increases dramatically when the field turns parallel to the 2D plane. Such behavior is counterintuitive and qualitatively different from that in GaAs-based structures.

#### V. DISCUSSION

In the present study, by using a magnetoresitance tensor measurements technique in a tilted magnetic field, we extracted EEC and explored Zeeman effects in conductivity. We demonstrated the fruitfulness of this approach and revealed the anticipated<sup>11</sup> high-field logarithmic asymptotics of the EEC.

Our measurements also reveal several puzzling features of the magnetotransport in Si-MOSFETs. Firstly, the low-field drop of the EEC (i.e., the increase in Hall resistance), detected in our experiments, lacks an explanation. In order to clarify this issue, one requires more precise very-low-field Hall measurements with a variety of samples ranging in mobility and conductance values, as well as a theoretical framework to treat the problem.

Another important observation is that the parallel field magnetoresistance is not produced by EEC solely. This observation poses a question of the applicability of the EEC theory for the determination of the interaction constant from the parallel field magnetoresistance.<sup>18,25,37</sup> Indeed, our data prove that there is another unexplored mechanism that also contributes to parallel field magnetoresistance; it is necessary to disentangle different MR mechanisms, before extracting the Fermi-liquid constant.

Finally, our key result is that the parallel field magnetoresistance is suppressed by a rather insignificant nonquantizing perpendicular field component. This result directly contradicts the predictions of the electron-electron interaction theory.<sup>52</sup> If the parallel field magnetoresistance was caused by EEC, such behavior could be straightforwardly explained by a complete suppression of magnetoresistance already at  $\mu B_{\perp} =$ 1, according to Eq. (2). However, we have shown above, that EEC is too small and alone can not be a reason for the parallel field magnetoresistance. According to Eq. (2), it means that the parallel field MR comes from mobility renormalization.

There are several potential mechanisms of such renormalization: (i) the mobility may drop with parallel field due to finite width effects.<sup>29</sup> This mechanism, however, is not supported by our data (compare the  $90^{\circ}$  and  $75^{\circ}$  curves in Fig. 5 that show a factor of 3 diminished magnetoresistance in almost the same parallel field) and is not very probable because of the thin potential well in Si-MOSFETs (~3 nm) compared to the magnetic length  $l_B[nm] = 25.7(B_{\parallel}[T])^{-0.5}$ ; (ii) the mobility may depend on the Zeeman splitting in agreement with the predictions of the screening theory.<sup>27–29</sup> The latter mechanism should produce direction-independent positive magnetoresistance, exactly the behavior observed in heavily doped multisubband thin Si quantum wells.<sup>64</sup> This, however, does not reconcile with our data. (iii) Surface roughness could also affect MR through the weak localization suppression,<sup>63</sup> however, this mechanism is hardly relevant because it produces a negative MR in contrast to our observations.

Experimentally, we observe a picture opposite to the common sense arguments: the parallel field magnetoresistance is strongly suppressed when the sample is rotated in fixed total field. This observation is not a property of particular studied samples, rather, there are numerous examples in literature where strong positive MR in parallel field coexists with almost shallow or even negative MR in a perpendicular or tilted field: for *p*-GaAs,<sup>65</sup> strained Si,<sup>66</sup> and Si/SiGe quantum wells.<sup>67</sup> A dramatic delocalizing effect of the perpendicular field was also reported for high mobility Si-MOSFET samples in the low-density/high resistivity ( $\rho \gtrsim 2\pi\hbar/e^2$ ) regime in the vicinity of the metal-insulator transition.<sup>68</sup> Such behavior is not explained at all and the question why the parallel field MR is suppressed by the perpendicular field component remains open.

We believe that the parallel field magnetoresistance suppression in perpendicular field is somehow related to the low-field Hall feature [region A in Fig. 1(g)]. The empiric crossover between the low- and high-field regimes  $B_{\rm crossover} \approx$  $\sqrt{B_{tr}^2 + (k_B T/g\mu_B)^2}$  points to the localization-related nature of the low-field Hall feature. We, therefore, suggest the following model: a small part of electrons is localized in low binding-energy states and coexist with mobile electrons. We stress that these states are different from conventional tail of localized states located below the mobility edge.<sup>33,34</sup> The localized electrons do not contribute to the low-field Hall coefficient because they can be treated as zero mobility carriers. Let us assume also that the localized states promote strong parallel field MR. This assumption does not contradict the empirical observations of the disorder effect in MR.<sup>31</sup> Application of a perpendicular field changes the symmetry class of the system, favors delocalization of these electrons and hence decreases the response of a 2D system to parallel magnetic field. Such explanation initiates questions about the source of 10–30% electrons that are out of the game in weak fields and about the mechanism of their influence on the parallel field MR.

The tilted field approach suggested in this paper might be applied for a similar study of EEC with high-mobility Si-MOSFETs where strong metallic conductivity ( $\partial \sigma / \partial T < 0$ ) and metal-insulator transition are considered to be driven by the EEC.<sup>69</sup> This task is, however, rather challenging experimentally because it requires a combination of millikelvin temperatures (to ensure the deep diffusive limit  $k_B T \tau / \hbar \ll 1$  for an order of magnitude higher mobility samples), field sweep, and sample rotation.

## VI. CONCLUSION

In this paper, we applied a phenomenological technique of resistivity tensor analysis to check the long-standing prediction by Lee and Ramakrishnan<sup>11</sup> about a Zeeman splitting dependence of the electron-electron interaction correction (EEC) to conductivity in the diffusive regime,  $k_B T \tau / \hbar \ll 1$ . Our measurements reveal distinctly different behaviors of the magnetotransport in the two domains of perpendicular field, the low- $B_{\perp}$  field (LF) and the high- $B_{\perp}$  field (HF) one.

In the LF domain, the 2D system demonstrates a strong and T-dependent magnetoresistance versus  $B_{\parallel}$  field, whereas the Hall angle exceeds the Drude value by up to 30%, depends on  $B_{\perp}$ , and grows as T decreases. This Hall anomaly obscures the determination of the quantum interaction correction from the magnetotransport data in the LF domain.

In the HF domain, the Hall anomaly is washed out by the  $B_{\perp}$  field that enables extracting the interaction quantum correction from experimental data. The EEC was found to be field direction independent, and linear in both  $\ln(T)$  and  $\ln(B)$ , as expected.

Remarkably, the magnitude of the experimentally determined EEC appeared to be more than a factor of 10 smaller than the parallel field magnetoconductance. Thus the parallel field MR observed in Si-MOSFETs is not explained by the EEC solely. Even more surprisingly, the observed strong parallel field MR quickly diminishes when the perpendicular field component is applied on top of the parallel field. This fact is a direct evidence for the nonpurely Zeeman origin of the parallel field magnetoresistance.

In total, our findings point at the incompleteness of the existing theory of magnetotransport in interacting and disordered 2D systems: too strong parallel field magnetoresistance, its suppression by a perpendicular magnetic field, and the low-field Hall anomaly require an explanation. We believe that these three phenomena are interrelated and originate from a destructive action of the perpendicular field on the localized states.

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## APPENDIX A: TEST OF THE APPLICABILITY OF THE HIGH-FIELD ASYMPTOTICS

In the original papers,<sup>11,12</sup> the interaction correction field dependence,  $\Delta\sigma(h)$ , is expressed via an integral with known low- and high-field asymptotics. This integral is inconvenient in handling, therefore, we used its analytical asymptotics, see



FIG. 6. Theoretical magnetic field dependence of the EEC, normalized by interaction factor. Solid line corresponds to high-field asymptotics (11), dotted curve corresponds to the approximation from Ref. 15 (see text), dashed and dash dotted curves are exact results for  $F_0^{\sigma} = -0.1$  and  $F_0^{\sigma} = -0.7$ , respectively. The curves are shifted vertically to achieve coincidence in the high-field limit.

Eq. (11), instead. In Fig. 6, we compare the exact result  $\Delta\sigma(h)$  for several  $F_0^{\sigma}$  values [see Eq. (15) in Ref. 12, note that the dimensionless field scale differs by a factor  $2\pi$ ] and high-field linear in  $\ln(B)$  asymptotics, see Eq. (11). To exclude an interaction constant dependence in the high-field limit, all results were divided by  $2n_v^2\lambda$ . Figure 6 shows that for h > 2, the exact result for different  $F_0^{\sigma}$  becomes indistinguishable from the logarithmic high-field asymptotics. At the same time, in the low-field regime, the curves substantially deviate from each other: the closer  $F_0^{\sigma}$  is to -1, the stronger is the magnetoconductance. This fact has a simple physical explanation: in the high-field limit,  $2n_v^2$  triplets (out of all  $4n_v^2 - 1$  triplet terms) become suppressed, thus excluding any dependence on  $F_0^{\sigma}$ . In the low-field regime, the closer  $F_0^{\sigma} \equiv (2/g^* - 1)$  is to -1 (i.e., to the Stoner instability), the larger is the effective g factor, and the stronger is the response of conductivity to magnetic field.

An alternative approach used in Ref. 15 is based on the approximation of the crossover function [see Eq. (4) from Ref. 15]. For comparison, we present this approximation also in Fig. 6.

From the practical point of view, the condition h > 2 means that the total magnetic field B[T] should exceed 2.69 T[K]. This inequality is valid for our low-temperature high-field data shown in Figs. 3 and 4.

### APPENDIX B: LOW-FIELD NONLINEARITY OF THE HALL RESISTANCE

The nonlinearity of the Hall resistance in the low field domain affects both  $\mu(B)$  and  $\Delta\sigma(B)$  dependencies due to the calculation procedure, based on Eq. (1). Most of scattering mechanisms and quantum corrections, including low-field weak localization and Maki-Thompson corrections, renormalize mobility  $\mu$  and do not renormalize the Hall effect.<sup>70</sup> EEC does affect Hall resistivity but has no peculiarities close to zero field. The low-field Hall feature is thus unexpected in theory, though its experimental observation is not surprising. The lack of agreement between low-field Hall resistance and quantum correction theory was pointed by Ovadyahu<sup>71</sup> and reported several times since then.<sup>10,53–55</sup> Although there are some theoretically suggested mechanisms,<sup>55,61,62</sup> this phenomenon is still poorly understood.



FIG. 7. (Color online)  $\Delta\sigma(B)$  dependencies for sample Si-40,  $n = 1.25 \times 10^{12} \text{ cm}^{-2}$  at T = 0.6 K for three cases: perpendicular magnetic field (dotted curve), perpendicular component of the field for the sample tilted by 45° (dashed line, almost indistinguishable by eye from the solid curve), and total magnetic field for the sample tilted by 45° (dash-dotted curve).

Let us briefly summarize our experimental observations of the low-field nonlinearity in the Hall resistance in Si-MOSFETs: (i) the effect weakens as temperature increases (see, e.g., Fig. 3). (ii) The amplitude of the effect may achieve  $10e^2/2\pi^2\hbar$  at low temperatures, i.e., variations in the Hall angle are as large as 30%. (iii) The  $\Delta\sigma(B)$  dependence is determined by the perpendicular field component. To prove this, we compare in Fig. 7  $\Delta\sigma(B)$  for the perpendicular field orientation,  $\Delta\sigma(B_{\perp})$ , and  $\Delta\sigma(B)$  for  $\theta = 45^{\circ}$ ; (iv) The field range, where the Hall resistance is nonlinear, broadens as density (and hence conductivity) decreases. (v) The effect is observed in low-mobility Si-MOSFETs ( $\mu \sim 0.2 \text{ m}^2/\text{Vs}$ ) in the temperature range  $0.3-15 \text{ K} (k_B T \tau/\hbar = 0.01-0.5)$ . For high-mobility samples ( $\mu > 2 \text{ m}^2/\text{Vs}$ ), we did not observe any nonlinearity in the Hall resistance down to  $0.05 \text{ K} (k_B T \tau/\hbar \approx 0.1)$ .

It might be that the low-field Hall nonlinearity is somehow related to weak localization, though weak localization itself does not produce a correction to the Hall coefficient. Indeed, let us estimate the transport field  $B_{\rm tr} = \Phi_0/4\pi l^2$  $[\Phi_0 = (2\pi\hbar c/e)]$ , that is, the typical value of a perpendicular field component where weak localization is suppressed. By substituting the transport mean free path *l* from the Drude formula  $l^{-1} = \rho_D \times (2e^2/2\pi\hbar) \times \sqrt{\pi n}$  for a twovalley system, we get  $B_{\rm tr} = n\rho_q^2 \times (2\pi\hbar c/e)$ , where  $\rho_q \equiv \rho_D \times (e^2/2\pi\hbar)$  is the dimensionless Drude resistivity and  $\rho_D$  for simplicity was taken equal to  $\rho(B = 0)$ ; this simplification is justified for  $\rho \ll 2\pi\hbar/e^2 \approx 26$  kOhm. For practical use,  $B_{\rm tr}[T] = 0.062 n [10^{12} {\rm cm}^{-2}] (\rho_D [{\rm kOhm}])^2$ . The coincidence of the estimated  $B_{\rm tr} \approx 1.25$  T value for the most intensively discussed density  $n = 1.25 \times 10^{12} {\rm cm}^{-2}$  with a characteristic field of the Hall anomaly suppression at the lowest temperature (see Figs. 1, 3, and 4) points to the relationship between weak localization and the anomalous low-field Hall slope.

Observation (iv) is in line with this scenario, because growth of the resistivity pushes  $B_{tr}$  to higher fields. A mechanism of the weak-localization-related low-field nonlinearity in the Hall resistance was suggested in Ref. 55, where the effect was interpreted as the second-order correction to conductivity, i.e., a crossed term of the EEC (which controls the amplitude of the effect) and weak localization (which controls the magnetic field dependence). In our case, however, the sign of the effect is opposite to that of Ref. 55, and the amplitude of the effect is much stronger.

Similar sign of the effect (i.e., Hall coefficient decreasing with field down to its nominal value 1/ne follows from memory effects.<sup>62</sup> However, the memory effects do not produce temperature dependent correction to Hall effect, as we observed. Interaction in the Cooper (particle-particle) channel<sup>56</sup> produces the so-called DoS correction, which is suppressed in magnetic fields of the order of  $B \propto T/\mu$ , similar to what is seen in experiment. The observed effect, however, is too big to be explained by quantum correction: indeed, were the Hall nonlinearity,  $\Delta\sigma_c \sim 10e^2/2\pi^2\hbar$ , caused by DoS correction, one would observe an enormous temperature dependence of the conductivity (of the insulting sign) at zero field  $\partial \sigma / \partial T \sim 10 e^2 / 2\pi^2 \hbar \times \ln(T) > 0$ , much stronger than both EEC and weak localization. The absence of such temperature dependence in our data points to the irrelevance of the DoS correction to the observed weak field Hall anomaly.

Another model that might explain the field-dependent Hall effect is a classical multi-component system. However, this model can hardly be applicable to our data because the Hall coefficient nonlinearity should be accompanied by a large positive magnetoresistance, and should occur in fields  $\sim 1/\mu$ , i.e., much higher than we observe. To conclude this discussion, the origin of the low-field Hall anomaly currently is not clear and requires both theoretical reconsideration and detailed experimental study.

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